

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher Supply, Demand and Key Producers, 2026-2032

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Abstracts

The global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market size is expected to reach \$ 33809 million by 2032, rising at a market growth of 7.1% CAGR during the forecast period (2026-2032).

Capacitive plasma (CCP) etcher and inductive plasma (ICP) etcher (CCP/ICP etchers) are the most widely used etching equipment. Plasma etching machines can be roughly divided into two categories according to different plasma generation and control technologies, namely capacitive plasma (CCP) etching machines and inductive plasma (ICP) etching machines. Among them, CCP technology has high energy but poor adjustability, and is suitable for etching hard dielectric materials; ICP technology has low energy but strong controllability, and is suitable for etching low-hardness or thin materials such as monocrystalline silicon and polycrystalline silicon. In 2025, global capacitive plasma (CCP) etcher and inductive plasma (ICP) etcher production reached approximately 23075 units. Upstream for CCP/ICP etchers centers on vacuum and gas delivery (pumps, valves, gauges, MFCs, gas cabinets), RF power delivery (generators, matching networks, bias supplies, and ICP coils/antennas), chamber and consumable materials (aluminum or stainless chambers with quartz/ceramic liners and coatings), wafer handling and thermal management (electrostatic chucks, backside helium, chillers/heaters), plus metrology/control modules such as endpoint detection (e.g., OES), sensors, and recipe/automation software—together forming the core cost and performance drivers of dry-etch platforms.

Capacitive plasma (CCP) etcher and inductive plasma (ICP) etcher are core dry-etch tools in semiconductor manufacturing. CCP systems (often parallel-plate RF reactors) remain widely used for general-purpose plasma etching and certain dielectric processes

due to mature architectures and broad process coverage. ICP systems, by coupling power inductively to generate high-density plasma, enable low-pressure operation with higher etch rates, improved profile control, and reduced damage—key advantages for advanced patterning and high-aspect-ratio structures. In high-volume manufacturing, “decoupled” concepts (separating plasma density from ion energy control) are commonly leveraged to balance throughput and device integrity.

This report studies the global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher production, demand, key manufacturers, and key regions.

This report is a detailed and comprehensive analysis of the world market for Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher and provides market size (US\$ million) and Year-over-Year (YoY) Growth, considering 2025 as the base year. This report explores demand trends and competition, as well as details the characteristics of Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher that contribute to its increasing demand across many markets.

Highlights and key features of the study

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher total production and demand, 2021-2032, (K Units)

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher total production value, 2021-2032, (USD Million)

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher production by region & country, production, value, CAGR, 2021-2032, (USD Million) & (K Units), (based on production site)

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher consumption by region & country, CAGR, 2021-2032 & (K Units)

U.S. VS China: Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher domestic production, consumption, key domestic manufacturers and share

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher production by manufacturer, production, price, value and market share 2021-2026, (USD Million) & (K Units)

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher production by Type, production, value, CAGR, 2021-2032, (USD Million) & (K Units)

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher production by Application, production, value, CAGR, 2021-2032, (USD Million) & (K Units)

This report profiles key players in the global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market based on the following parameters - company overview, production, value, price, gross margin, product portfolio, geographical presence, and key developments. Key companies covered as a part of this study include Lam Research, TEL, Applied Materials, Inc., Oxford Instruments, SPTS Technologies, Plasma-Therm, Gigalane, Samco Inc, Sentech, Torr International, etc.

This report also provides key insights about market drivers, restraints, opportunities, new product launches or approvals.

Stakeholders would have ease in decision-making through various strategy matrices used in analyzing the World Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market

Detailed Segmentation:

Each section contains quantitative market data including market by value (US\$ Millions), volume (production, consumption) & (K Units) and average price (K US\$/Unit) by manufacturer, by Type, and by Application. Data is given for the years 2021-2032 by year with 2025 as the base year, 2026 as the estimate year, and 2027-2032 as the forecast year.

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher Market, By Region:

United States

China

Europe

Japan

South Korea

ASEAN

India

Rest of World

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher Market,
Segmentation by Type:

Capacitive Plasma (CCP) Etcher

Inductive Plasma (ICP) Etcher

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher Market,
Segmentation by System Integration Method:

Single Chamber

Multi-chamber

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher Market,
Segmentation by Production Form:

Single-wafer

Batch

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher Market,
Segmentation by Automation Level:

Manual/Semi-automatic

Fully Automatic

Global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher Market, Segmentation by Application:

Semiconductors

Dielectrics

Metals

Others

Companies Profiled:

Lam Research

TEL

Applied Materials, Inc.

Oxford Instruments

SPTS Technologies

Plasma-Therm

Gigalane

Samco Inc

Sentech

Torr International

Trion Technology

Syskey Teconology

Korea Vacuum Tech

AMEC

NAURA

Jiangsu Leuven Instruments

Key Questions Answered:

1. How big is the global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market?
2. What is the demand of the global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market?
3. What is the year over year growth of the global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market?
4. What is the production and production value of the global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market?
5. Who are the key producers in the global Capacitive Plasma (CCP) Etcher and Inductive Plasma (ICP) Etcher market?
6. What are the growth factors driving the market demand?

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